## INDIAN J. CHEM., VOL. 14A, APRIL 1976



Fig. 2 — V versus t and  $\alpha_s$  plots for samples A and B of arsenic sulphide

Тав	le 1 — 5	Surface	Area VA Methol	LUES BY	BET, t	AND
Degas- sing temp. (°C)	Specific surface area (m <sup>2</sup> g <sup>-1</sup> )					
	SBET	St	Sa	SBET	St	Sa
	SAMPLE A			SAMPLE B		
27 60 110	42·0 40·7 40·7	42·7 41·3 41·8	44·2 42·5 44·2	113 <b>·2</b> 108·9 108·9	109·5 107·6 109·5	114·8 114·8 114·8

The  $\alpha_s$  plot is linear over the entire relative pressure range and passes through the origin. This indicates that the sample is non-porous or contains pores of width more than 200 Å (ref. 5). The *t* plot which also passes through the origin is linear up to a certain range only. At *t* values of 10 Å for sample A and 6 Å for sample B, the experimental curve deviates upwards from linearity indicating that more nitrogen is taken up than corresponding with multilayer adsorption. This indicates that the capillary condensation starts setting in at this point in the intermediate pores<sup>6</sup>.

The agreement of surface area of the samples between t and  $\alpha_s$  methods and BET method indicates that the former two methods can be used to analyse the adsorption data of the present sulphides.

The authors are grateful to the Head, Chemical Engineering Division, BARC Bombay, for providing facility to carry out the adsorption measurements.

## References

 BRUNAUER, S., EMMETT, P. H. & TELLER, N., J. Am. chem. Soc., 60 (1938), 370.

- EMMETT, P. H., A.S.T.M. symposium on new methods for particle size determination in the sub-sieve range, 1941, 95: Adv. Colloid Sci., 1 (1942).
- 95; Adv. Colloid Sci., 1 (1942), 3.
  3. VENUGOPAL CHETTY, K. & NAIDU, P. R., Proc. Indian Acad. Sci. Sect. A, 79 (1) (1974), 26.
- 4. LIPPENS, B. C. & DE BOER, J. H., J. Catalysis, 4 (1965), 319.
- 5. SING, K. S. W., Proceedings of international symposium on surface area determination (Butterworths, London), 1969, 25.
- 6. BROEKHOFF, J. C. P. & DE BOER, J. H., Proceedings of international symposium on surface area determination (Butterworths, London), 1969, 97.

## Photo-stabilization of Butyl Rubber in Solid State by Phenyl Allyl Mercury

RAMESH CHANDRA & HARI L. BHATNAGAR

Department of Applied Sciences & Humanities Kurukshetra University, Kurukshetra

Received 22 May 1975; accepted 1 December 1975

The incorporation of 0.5% PAM or more in the matrix of butyl rubber film irradiated by 366 nm exercises a protective influence on the photo-oxidative degradation of butyl rubber.

THE kinetics of photo-oxidative degradation of butyl rubber in the presence of oxygen and its photo-stabilization by the addition of 0.1% (wt/wt) phenyl allyl mercury <sup>1,2</sup> (PAM) were reported earlier<sup>3</sup>. In the present note, the physico-chemical studies have been conducted to find out an optimum limit of [PAM] which would impart the saturation photo-stabilization to butyl rubber in solid state. NOTES CALCULATION









The preparation of butyl rubber films, the method of incorporation of [PAM] into the matrix of films, the procedures of photo-irradiation, the subsequent dissolution of films and the characterization of molecular weight have been described elsewhere<sup>3</sup>.

The changes in the molecular weight as a function of [PAM] and time of irradiation were determined using light scattering technique.

Fig. 1 gives the values of the ratios of the weight average degree of polymerization  $(p_{w,t}/p_{w,o})$  for butyl rubber with or without [PAM] versus the irradiation time at 283°K. Fig. 2, gives the variation of the degree of degradation per original chain length ( $\alpha$ ) with the time of irradiation.

The data plotted in Figs. 1 and 2 indicate that incorporation of 0.5% PAM or more in the matrix of butyl rubber film irradiated with  $\lambda = 366$  nm exercises a protective influence on the photo-oxidative degradation of butyl rubber. These results are also supported by the values of the specific rate constant  $(k_1)$  at different concentrations of PAM (from 0.1 to 2.0%). The values of  $k_1$  are negligible beyond 0.5% PAM.

## References

- 1. ROLL, K. B. & PETROV, A. A., Zh. obshch. Khim., 32 (1962), 1095.
- RAZUVAEW, G. A., LATYAEVA, V. I. & VYSHINSKAYA, L. I., Zh. obshch. Khim., 31 (1961), 2667.
- 3. CHANDRA, R. & BHATNAGAR, H. L., Indian J. Chem., (in press).